AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

1-8. (Canceled)

9. (New) A method of making an active matrix substrate, the method comprising:
forming switching elements disposed in a shape of a matrix, gate signal lines
controlling the switching elements and extending in a first direction, and source signal
lines connected to the switching elements and extending in a second direction
perpendicular to the first direction on a front surface of a light permeable substrate;

forming an interlayer insulating film on the switching elements, the gate signal lines, and the source signal lines;

forming on the interlayer insulating film a negative type photosensitive transparent conductive material whose exposed parts are left in a pattern;

performing exposure from a back surface side of the light permeable substrate in order to expose the negative type photosensitive transparent conductive material in a self-alignment fashion by using the gate signal lines and the source signal lines as exposure masks;

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developing the negative type photosensitive transparent conductive material so as to obtain pixel electrodes by removing unexposed parts of the negative type photosensitive transparent conductive material.

- 10. (New) The method of claim 9, wherein the negative type photosensitive conductive material comprises photosensitive resin and conductive particles dispersed in the photosensitive resin.
- 11. (New) The method of claim 10, wherein the conductive particles comprise indium tin oxide, antimony tin oxide, or zinc oxide.
- 12. (New) The method of claim 9, wherein the negative type photosensitive conductive material comprises at least one coloring agent.
- 13. (New) A method of making a flat panel display comprising the method of claim 9 for making the active matrix substrate of the flat panel display.
- 14. (New) A method of making a flat panel image sensing device comprising the method of claim 9 for making the active matrix substrate thereof.